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ATTORNEY DOCKET NO. CONFIRMATION NO. FIRST NAMED INVENTOR APPLICATION NO. FILING DATE 015290-592 1155 02/15/2002 Jeffrey Hung 10/075,602 EXAMINER 03/10/2004 7590 UMEZ ERONINI, LYNETTE T Peter K. Skiff BURNS, DOANE, SWECKER & MATHIS, L.L.P. PAPER NUMBER ART UNIT P.O. Box 1404 1765 Alexandria, VA 22313-1404

DATE MAILED: 03/10/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

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	App	lication No.	Applicant(s)	
•	10/0	075,602	HUNG ET AL.	
Office Action Summary		miner	Art Unit	
		ette T. Umez-Eronini	1765	
The MAILING DATE of this of Period for Reply	communication appears	on the cover sheet with the	correspondence address	
A SHORTENED STATUTORY PE THE MAILING DATE OF THIS CO - Extensions of time may be available under the after SIX (6) MONTHS from the mailing date of - If the period for reply specified above is less the - If NO period for reply is specified above, the no - Failure to reply within the set or extended per - Any reply received by the Office later than thre - earned patent term adjustment. See 37 CFR	OMMUNICATION. provisions of 37 CFR 1.136(a). I f this communication. nan thirty (30) days, a reply within naximum statutory period will apply od for reply will, by statute, cause months after the mailing date o	n no event, however, may a reply be the statutory minimum of thirty (30) of y and will expire SIX (6) MONTHS fro the application to become ABANDOI	timely filed lays will be considered timely. om the mailing date of this communic NED (35 U.S.C. § 133).	ation.
Status				
 1) Responsive to communication 2a) This action is FINAL. 3) Since this application is in colored in accordance with the 	2b)⊠ This action condition for allowance e	n is non-final. xcept for formal matters, p		ts is
Disposition of Claims				
4) Claim(s) 14,18,21,28,29 and 4a) Of the above claim(s) is/are allowed for Claim(s) 14,18,21,28 and 3 7) Claim(s) 29 is/are objected 8) Claim(s) are subject Claim(s)	is/are withdrawn fro ed. <u>1-33</u> is/are rejected. to. to restriction and/or elec	om consideration.		
9) The specification is objected 10) The drawing(s) filed on Applicant may not request that Replacement drawing sheet(s) 11) The oath or declaration is ob	is/are: a) accepted any objection to the drawi including the correction is	ng(s) be held in abeyance. s required if the drawing(s) is	See 37 CFR 1.85(a). objected to. See 37 CFR 1.1	
Priority under 35 U.S.C. § 119				
12) Acknowledgment is made of a) All b) Some * c) Not the Certified copies of the Some * c). Certified copies of the Certified	one of: e priority documents have priority documents have d copies of the priority d nternational Bureau (PC	ve been received. ve been received in Applic ocuments have been rece CT Rule 17.2(a)).	eation No sived in this National Stage	е
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing 3) Information Disclosure Statement(s) (PT		4) Interview Summ Paper No(s)/Mai 5) Notice of Inform 6) Other:	ary (PTO-413) I Date al Patent Application (PTO-152)	

Art Unit: 1765

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DETAILED ACTION

Claim Rejections - 35 USC § 102

1. The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

- (e) the invention was described in (1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent or (2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effects for purposes of this subsection of an application filed in the United States only if the international application designated the United States and was published under Article 21(2) of such treaty in the English language.
- 2. Claims 18 is rejected under 35 U.S.C. 102(e) as being anticipated by Abraham (US 6,004,884)

Abraham shows an example of a first chemistry Cl₂/Ar/CHF₃ etch of a wafer in a plasma reactor (column 10, lines 33-36), see TABLE 1 below.

TABLE 1

FIRST CHEMISTRY		TOP POWER	BOTTOM POWER	Į.	FLOW RAT	E .
	Range	350-650	100-350	30 sccm- 110 sccm Cl ₂	12.5%-30% (of Cl ₂ flow) CHF ₃	19%–50% (of Cl₂ flow) At
R: M	Preferred Range	400-600	120-200	35 scen- 80 scen Cl ₂	15%-25% (cf Cl ₂ flow) CHF,	25%-40% (of Cl ₂ flow) Ar
	More Preferred Range	560	140	40 sccm Cl ₂	17.5% (of Cl ₂ flow) CHF ₃	37.5% (of Cl ₂ flow) Ar

This example reads on, an oxygen-free plasma etching gas formulation comprising: CHF₃, argon, and chlorine, the gas formulation being free of SF₆, and encompassing a ratio of flow rates of CHF3: argon: chlorine in the formulation is 5 to 80

Art Unit: 1765

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sccm: 5 to 80 sccm: 5 to 60 sccm, **in claim 18**. No patentable weight is given to the phrase, "for removing an organic ARC on a metallic layer." Likewise the intended use of composition is not patentably significant. *In re Albertson* 141 USPQ 730 (CCPA 1964); *In re Heck* 114 USPQ 161 (CCPA 1957).

Claim Rejections - 35 USC § 103

- 3. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 4. This application currently names joint inventors. In considering patentability of the claims under 35 U.S.C. 103(a), the examiner presumes that the subject matter of the various claims was commonly owned at the time any inventions covered therein were made absent any evidence to the contrary. Applicant is advised of the obligation under 37 CFR 1.56 to point out the inventor and invention dates of each claim that was not commonly owned at the time a later invention was made in order for the examiner to consider the applicability of 35/Ú.S.C. 103(c) and potential 35 U.S.C. 102(e), (f) or (g) prior art under 35 U.S.C. 103(a).
- 5. Claims 14 and 28 are rejected under 35 U.S.C. 103(a) as being unpatentable over Abraham (US 5,846,443).

Abraham teaches an etchant gas composition that comprises Cl₂, HCl, and CHF₃ (Abstract, column 6, lines 54-56) and further teaches "It is contemplated that some

Art Unit: 1765

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additives, e.g., N_2 , may be added if desired" (column 6, lines 63-64), which reads on an oxygen-free plasma etching gas formulation comprising CHF₃ and HCl, and the gas formulation being free of SF₆.

Abraham differs in failing to teach the etchant comprises argon.

Gases such as nitrogen and noble gases such argon are known inert gases that are used as carriers and dilurents.

It would have been obvious to one to having ordinary skill in the art at the time of the claimed invention to modify Abraham by using argon for the purpose of obtaining the claimed invention.

6. Claims 14, 21, 29 and 31-33 are rejected under 35 U.S.C. 103(a) as being unpatentable over Nishitani et al. (US 5,498,768).

Nishitani teaches, "... plasma treatment ... using halogen-containing chemical etching gases ... such as Cl₂, BCl₃, CCl₄, C₂Cl₄, SiCl₄, NF₃, CF₄, CHF₃, SF₆ and SiF₄ each alone or as a mixture thereof with inert gases such as Ar" (column 5, lines 24-32), which comprises an oxygen-free plasma etching gas formulation comprising: CHF₃, Ar and BCl₃, in claim 14, and 29; and (i) more than one fluorine containing compound, (ii) an inert carrier gas selected from the group consisting of argon, and (iii) chlorine, in claim 21 and 31.

Nishitani succeeds at disclosing plasma gas components corresponding to those claimed by applicants. It is noted that the reference is silent about a specific combination of gases corresponding to those claimed by applicants.

Art Unit: 1765

It would have been obvious to one having ordinary skill in the art at the time of the claimed invention to select any combination of disclosed etchant gases, including those defined in applicants' claims because Nishitani illustrates that such gases are known to be suitable etchant gases.

Nishitani further differs in failing to teach the gas formulation wherein the inert carrier gas is neon and helium respectively, in claims 32 and 33.

It is the examiner's position that inert gases such as helium and neon are known and are used as diluents and that it would have been obvious to one to having ordinary skill in the art at the time of the claimed invention to modify Nishitani by using a known inert gas for the purpose of obtaining the claimed invention.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Lynette T. Umez-Eronini whose telephone number is 571-272-1470. The examiner is normally unavailable on the First Friday.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nadine Norton can be reached on 571-272-1465.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should

Page 6

Application/Control Number: 10/075,602

Art Unit: 1765

you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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March 2, 2004

NADINE G. NORTON PRIMARY EXAMINER